Form PTO-1449 Applicant: Serial No.: Filing Date

For

Tasuaki Hashizume et al. 10/598 856

| Sheet 1 of 2 hizume et al. | Confirmation No.; 1386 | Art'y Docket No.; 14321.92

Art Unit: 2874

September 13, 2006

WAVEGUIDE TYPE VARIABLE OPTICAL ATTENUATOR

INFORMATION DISCLOSURE CITATIONS MADE BY APPLICANT

U.S. Patent Documents

Examiner	Document	Issue	
Initial*	Number	Date	Name

Foreign Patent Documents

Examiner Initial*	Document Number	Publication Date	Country or Patent Office	Translation
1	2001-507817	06/12/2001	Japan	No
2	2004-133389	04/30/2004	Japan	No
3	WO 08/20760	07/09/1998	PCT	N/A

Other Documents (including author, title, pertinent pages, etc.)

Examiner Initial*

- 4 Yasuyuki Inoue et al., Polarization Sensitivity of a Silica Waveguide Thermooptic Phase Shifter for Planar Lightwave Circuits, IEEE, Photonics Technology Letters, Vol. 4, No. 1, January 1992, pp. 36-38.
 - _5 Na Young Kim et al, Limitation of PMD Compensation Due to Polarization-Dependent Loss in High-Speed Optical Transmission Links, IEEE, Photonics Technology Letters, Vol. 14, No. 1, January 2002, pp. 104-105.
 - 6 G Heise et al., Simple Model for Polarization Sensitivity of Silica Waveguide Mach-Zehnder Interferometer, IEEE, Photonic Technology Letters, Vol. 17, No. 10, October 2005, pp. 2116-2118.
- R. Narevich et al., Novel Wide-Band Low-PDL Integrated Variable Optical Attenuator in Silicaon-Silican, Optical Fiber Communication Conference, Technical Digest OFC/NFOEC, Vol. 4, 2005

Examiner: Date Considered:

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609, draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

 Form PTO-1449
 Sheet 2 of 2

 Applicant:
 Tasuaki Hashizume et al.
 Confirmation No.: 1386

 Serial No.:
 10/598,856
 Art'v Docket No.: 1432/10.

Filing Date September 13, 2006 Art Unit: 2874

WAVEGUIDE TYPE VARIABLE OPTICAL ATTENUATOR

References Cited by Applicants

While the filing of Information Disclosure Statements is voluntary, the procedure is governed by the guidelines of Scotton 609 of the Manual of Pattert Examining Procedure and 37 C. P. R. § 8, 19 and 19. R. To be considered a perinformation Disclosure Statement, Form PTO-149 shall be accompanied by a copy of each listed patent or publication or torther item of information and a translation of the pertinent portions of foreign documents (if an existing translation readily available to the applicant), an explanation of relevance of each reference not in the English language, and should be submitted in a fixed yearner as each in MPPS Sec. or in MPPS Sec. and in MPS Sec. and

Examiners will consider all citations submitted in conformance with 37 C.F.R. § 1.98 and MPEP Sec. 609 and place their initials adjacent the citations in the spaces provided on this form. Examiners will also initial citations not in conformance with the guidelines which may have been considered. A reference may be considered by the Examiner for any reason whether or not the citation is in full conformance with the guidelines. All post in the paidelines. A line will be drawn through a citation if it is not in conformance with the guidelines APD has not been considered. A copy of the submitted form, as reviewed by the Examiner, will be returned to the applicant with the next communication. The original of the form will be entered into the application file.

Each citation initialed by the Examiner will be printed on the issued patent in the same manner as references cited by the Examiner on Form PTO-892.

The reference designations "A1," "A2," etc. (referring to Applicant's reference 1, Applicant's reference 2, etc.) will be used by the Examiner in the same manner as Examiner's reference designations "A," "B," "C," etc. on Office Action Form PTO-1142.

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For:

Examiner: Date Considered: